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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/506,458	09/01/2004	Ho Sung Kim	P/3653-10	9993	
38107	7590 02/22/2006		EXAMINER		
PHILIPS INTELLECTUAL PROPERTY & STANDARDS			ZEMEL, IRINA SOPJIA		
595 MINER CLEVELAN	ROAD ID, OH 44143	ART UNIT	PAPER NUMBER		
,			1711	1711	
	·		DATE MAILED: 02/22/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

V.

	Application No.	Applicant(s)			
	10/506,458	KIM, HO SUNG			
Office Action Summary	Examiner	Art Unit			
	Irina S. Zemel	1711			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DATE - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period was precised to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	l. ely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) ☐ Responsive to communication(s) filed on 30 November 2005. 2a) ☐ This action is FINAL. 2b) ☐ This action is non-final. 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
 4) Claim(s) 1-9 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-9 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 					
Application Papers					
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Examine 11.	epted or b) objected to by the Eddrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P				

DETAILED ACTION

The rejection not addressed below are deemed withdrawn.

Claim Rejections - 35 USC § 102/203

The text of those sections of Title 35, U.S. Code not included in this action can

be found in a prior Office action.

Claims 1-9 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the

alternative, under 35 U.S.C. 103(a) as obvious over AU Patent Application 200151857

to De Toffol (hereinafter AU De Toffol) or under 35 U.S.C. 102(a and e) as anticipated

by or, in the alternative, under 35 U.S.C. 103(a) as obvious over its US corresponding

patent 6,476,087 to De Toffol (hereinafter US De Toffol).

The rejection stands as per reasons of record.

Response to Arguments

Applicant's arguments filed 11-30-2005 have been fully considered but they are

not persuasive. The applicants argue that the cited reference discloses a process

where the microspheres are evenly distributed in the liquid phase binder and, therefore,

do not float to the top of the of the mixture and do not achieve packing achieved by the

present invention and discussed on pages 4 and 5 of the specification. The examiner

disagrees with the applicants statement that the microspheres do not float to the top.

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While the reference does not expressly address this behavior of the microspheres during the foam formation, the miscrospheres., as discussed in the previous office action, the slow process of soaking the liquid phase inherently results in microspheres (at least a portion of microspheres) to float to the top of the mixture due to its buoyant nature. The claims of the instant application do not specify any desired degree or amount of microspheres floating on top of the mixture and this claim limitation is met by any relatively small amount of microspheres floated to the top of the mixture. The burden was shifted to the applicants to provide evidence that mo microdspheres of the compositions disclosed in De Toffol are floating to the top of the mixture upon slow draining or soaking of th solvent. The applicants provided none other than mere statement that since the miscrospheres a r evenly dispersed in the liquid phase binder they do not float to the top. It is quite possible that the microspheres, originally and prior to being poured into the mold, are uniformly dispersed in the liquid binder (so, by the way, are the microspheres of the resent invention). However, as discussed in the previous office action, upon sitting in the mold during slow process of solvent removal, at least some of the mirospheres must float to the top due to their buoyant nature. Furthermore, by draining all of the excess of liquid phase, it is reasonable believed that the microspheres become inherently closed packed and reach the bottom of the mold.

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The applicants further argue that De Toffol has a different aim and uses a different method in manufacturing the foams. The applicants state that a per claim 30, the process of De Toffol achieves foams "wherein the total interstitial void space

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is greater than the total microsphere void space", which is different from the objective of the present invention as shown in figures 1C and 1D of the instant application. First of all, In response to applicant's argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., interstitial void space or any measure of the voids between the microspheres) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

Furthermore, the claimed interstitial void space of the De Toffol reference only represent one of the preferred embodiments. The reference further expressly discusses in column 3, starting at line 37, "As indicated above, the porosity of the syntactic foam is a combination of the void volume of the microspheres and the interstitial void volume between the microspheres. An advantage of the preferred form of the invention is that the method allows for high interstitial void volume to be produced because adequate coating of the microspheres can occur using low amounts of polymer. The method also does not induce forces in the mix that results in increased packing of the microspheres. As such, it is possible using the method of the invention to lower the density of the syntactic foam by creating a high interstitial void volume. The applicant has found that the density of the syntactic foam produced by the method of the present invention is lowest when the interstitial void volume is greater than the total void volume of the microspheres. Thus, the greater proportion of porosity in the low density syntactic foam of the present invention". Thus the reference

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provides expressed teaching and motivation to ether increase or decrease the interstitial void volume depending on the desired characteristics of the final foams.

The applicants argue that with respect to the draining step, the reference discloses use of porous wick to absorb the excess liquid phase binder, rather than draining the excess binder as described and claimed. In interpreting the claimed limitation "draining" the examiner turned to a dictionary. The Cambridge dictionary definition of the word "drain" is – "to cause (a liquid) to flow away or cause a liquid to flow away from (something), leaving it dryer, or to become dryer as a liquid flows away". Removal of liquid from the composition by soaking liquid away is fully consistent with the above definition. Therefore, it is not seen how the claimed limitation of draining distinguishes over the cited art step of removal of liquid from the composition. Mere statement by the applicants that "soaking is not draining", thus, appears to be not only unconvincing, it also appears to be contrary to the common definition of the term "drain".

The invention as claimed, thus, is still considered to be unpatentable over the disclosure of the cited references.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the

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shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Irina S. Zemel whose telephone number is (571)272-0577. The examiner can normally be reached on Monday-Friday 9-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on (571)272-1078. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Irina S. Zemel Examiner Art Unit 1711

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